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STN: Cas, Japlo

(FILE 'HOME' ENTERED AT 10:29:24 ON 24 JUL 2002)

FILE 'CA' ENTERED AT 10:29:29 ON 24 JUL 2002

L1 389636 S NITRID? OR SI3N4 OR CON OR HFN OR TIN OR WN OR SI(3W)N  
L2 2120602 S SIO OR SIO2 OR OXIDE# OR ?SILICAT? OR SOG OR GLASS? OR BSG OR  
L3 1660967 S ?ETCH? OR PATERN? OR PATTERN? OR REMOV?  
L4 795819 S PLASMA# OR SPUTTER? OR CORONA# OR RIE OR MRIE OR MERIE OR GLO  
L5 657123 S CH2F2 OR CH3F OR CHF3 OR CH4 OR ACETYLENE? OR METHAN? OR HYDR  
L6 11873 S CF4 OR C2F6 OR C4F8 OR C5F6 OR C5F8 OR PERFLUOROMETHAN? OR PE  
L7 12002 S ETHANE(3A)HEXAFLUORID? OR PERFLUOROBUTEN? OR FLUOROCARBON

FILE 'REGISTRY' ENTERED AT 10:35:21 ON 24 JUL 2002

L8 159 S CH2F2/MF OR CH3F/MF OR CHF3/MF OR CH4/MF OR CH2/MF OR C2H4/MF  
L9 55 S CF4/MF OR C2F6/MF OR C4F8/MF OR C5F6/MF OR C5F8/MF  
L10 21015 S NITRIDE/CNS

FILE 'CA' ENTERED AT 10:36:43 ON 24 JUL 2002

L11 46897 S L3(10A)L4  
L12 12986 S L2 AND L11  
L13 2639 S L12 AND L10  
L14 3242 S L12 AND L1  
L15 3351 S L13 OR L14  
L16 545 S L15 AND (L5 OR L8)  
L17 333 S L16 AND (L6 OR L7 OR L9)  
SAVE ETCHL17/A L17  
L18 144 S L17 AND (ETCHSTOP? OR STOP? OR SELECT?)  
L19 189 S L17 NOT L18  
SAVE ETCHL18/A L18  
SAVE ETCHL19/A L19  
L20 208 S L17 AND (WAFER# OR SEMICONDUCT? OR CHIP#)  
L21 95 S L18 AND L20  
L22 113 S L19 AND L20  
L23 125 S L17 NOT L20  
SAVE ETCHL21/A L21  
SAVE ETCHL22/A L22  
SAVE ETCHL23/A L23  
L24 49 S L18 AND L23  
L25 76 S L23 NOT L24  
SAVE ETCHL24/A L24  
DEL POLISHL31/A  
DEL RESISTL21/A  
DEL RESISTL29/A  
SAVE ETCHL25/A L25

FILE 'JAPIO' ENTERED AT 10:48:38 ON 24 JUL 2002

L26 22 S L17  
L27 18 S L26 AND (WAFER# OR SEMICONDUCT? OR CHIP#)  
L28 7 S L26 AND (ETCHSTOP? OR STOP? OR SELECT?)  
L29 19 S L27 OR L28  
L30 22 S L26 OR L29

FILE 'CA' ENTERED AT 10:54:44 ON 24 JUL 2002

SAVE ETCHL17/A L17

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